

21 (3) a photoinitiator, and which is adapted to be exposed and developed using an i-line stepper which uses monochromatic light, the polyimide precursor being such that a 20 μ m thick film thereof has a transmittance, at 365nm, of at least 40%.

22 31. (Twice Amended) A photosensitive resin composition for i-line stepper using monochromatic light, which comprises (1) a polyimide precursor, formed from an oxydiphthalic acid or acid anhydride thereof with a diamine, (2) an addition-polymerizable compound and (3) a photoinitiator, the polyimide precursor being such that a 20 μ m thick film thereof has a transmittance, at 365nm, of at least 40%.

Please add the following new claim to the application:

23 --37. A photosensitive resin composition according to claim 10, wherein said polyimide precursor is formed from the oxydiphthalic acid or acid anhydride thereof as a reactant and a diaminodiphenyl ether as a diamine reactant.--
